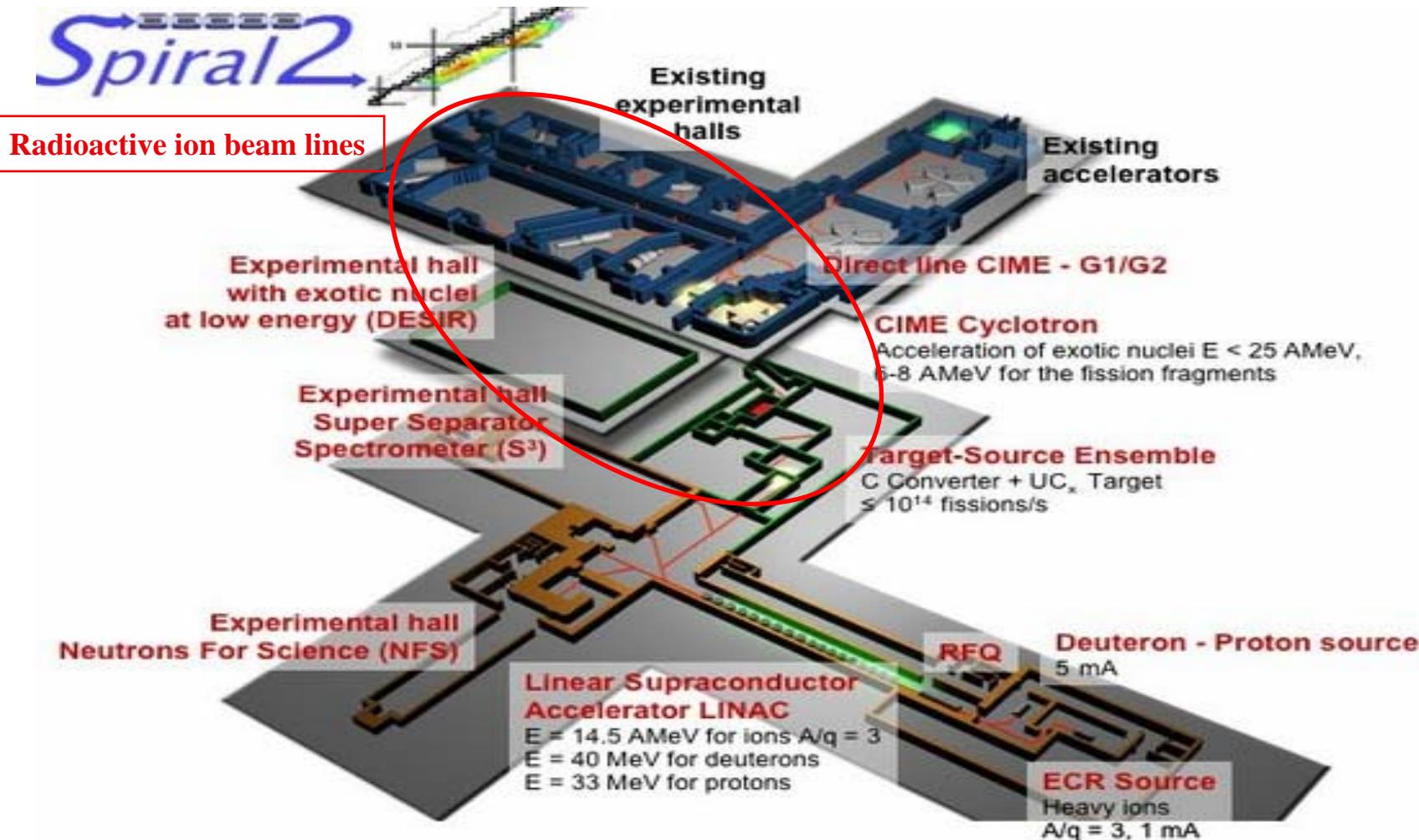
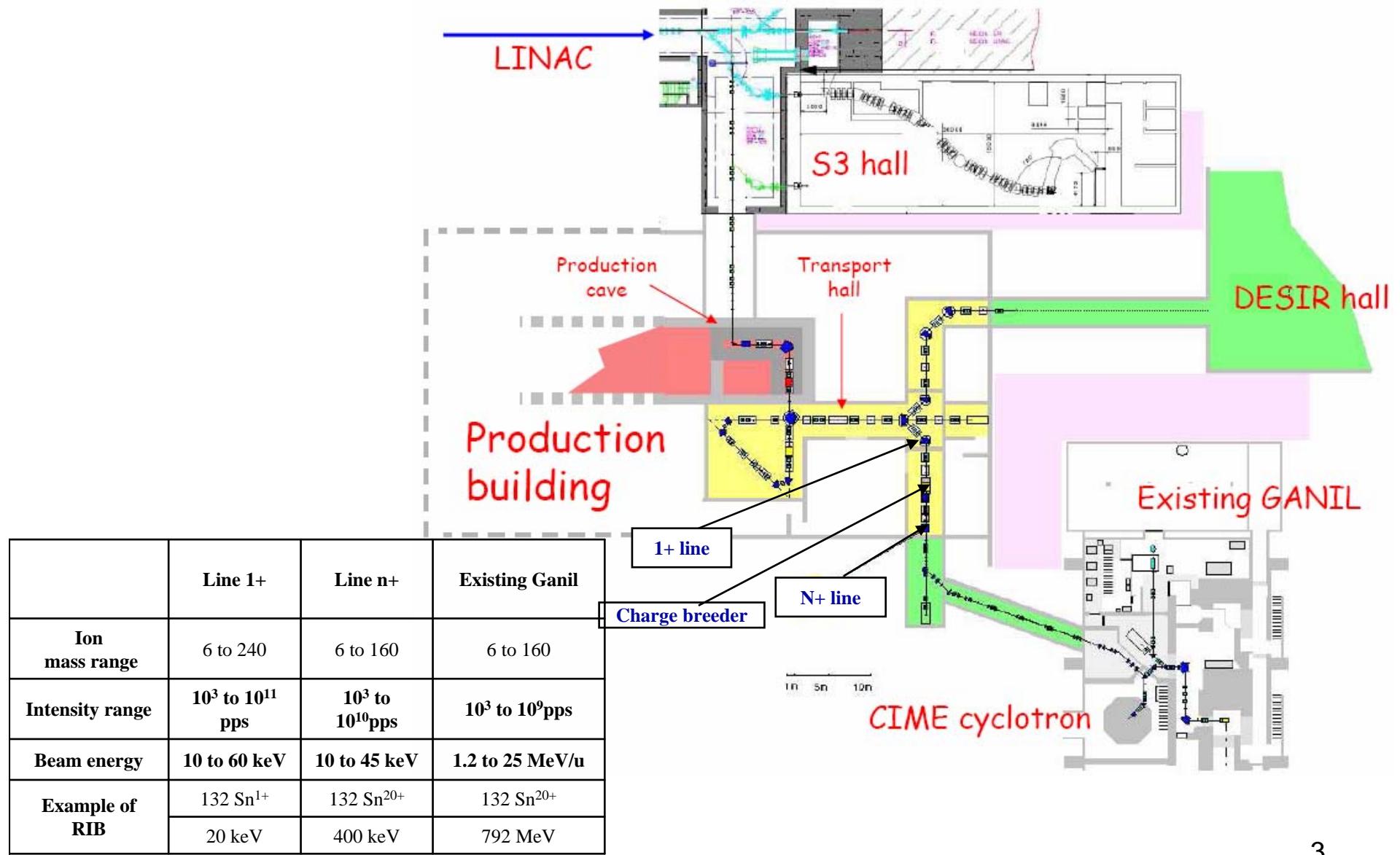


- contents

- SPIRAL 2 installation overview
- RIB lines description
- Radioactive Ion Beam profilers
 - Low Pressure Gas Monitor (LPGM)
 - Emissive Foil Monitor (EFM)
 - Very Low intensity Monitor (VLIM)
- Associated electronic



Radioactive Ions Beams description



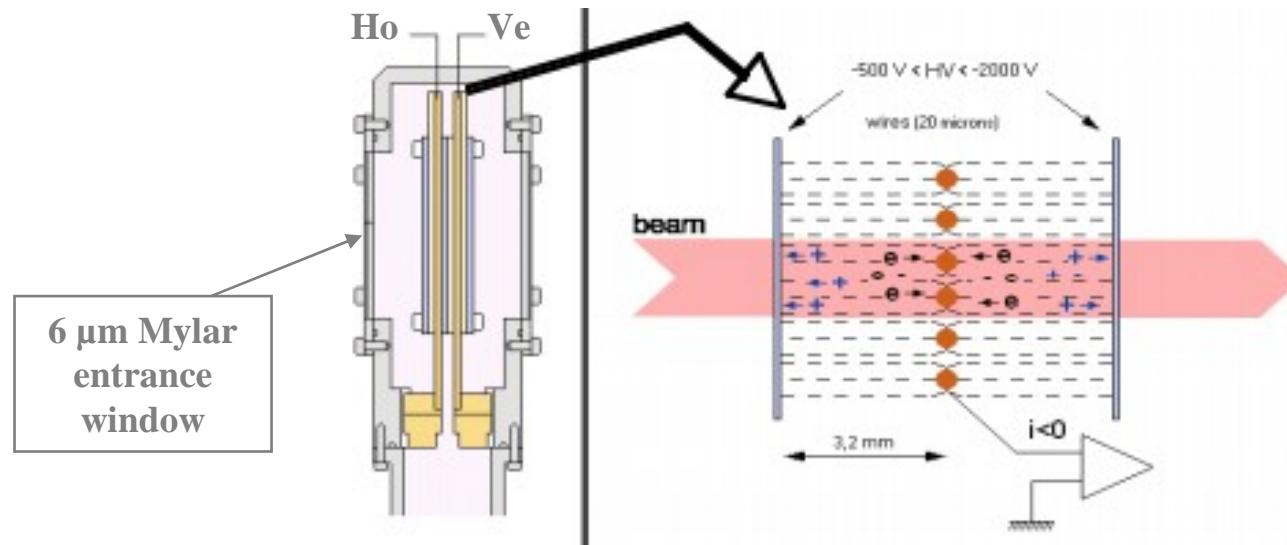
- **Low Pressure Gas Monitor (LPGM)**

Principle : ionization chamber with two wire planes in 10 mBar of C₃F₈ gas

Energy range : from 0.5 MeV/u to 25 MeV/u

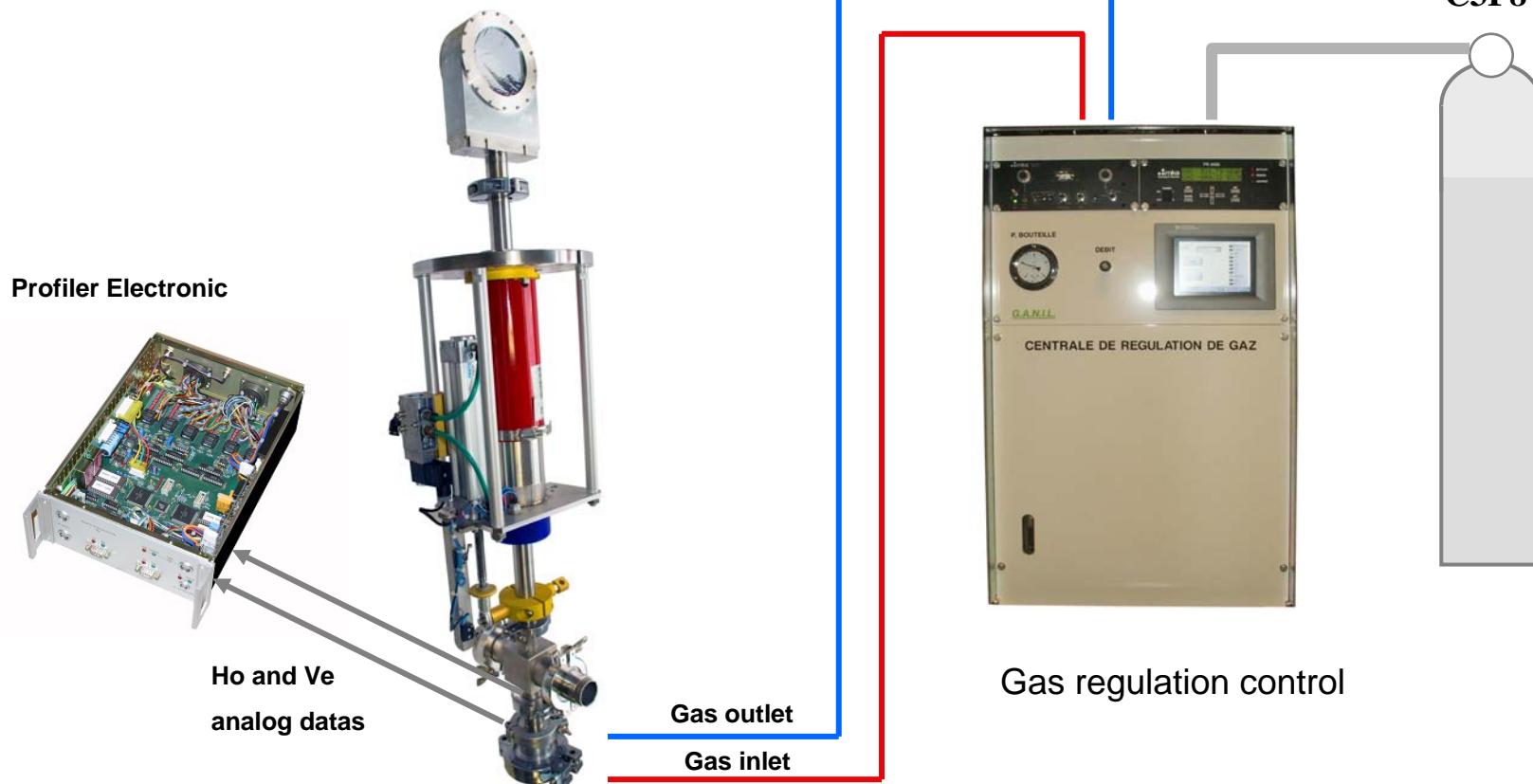
Intensity range : from 10² pps to 10⁷ pps

Location lines : from CIME to GANIL Experimental rooms



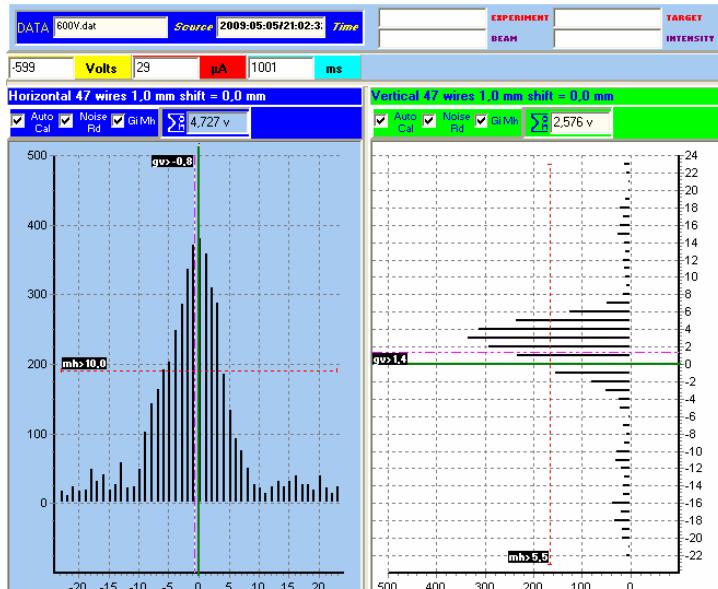
- **Low Pressure Gas Monitor (LPGM)**

Pressure : gas regulation between 5 to 50 mbar
 (usually 10 mbar)
High voltage : from -300V to -1000 V



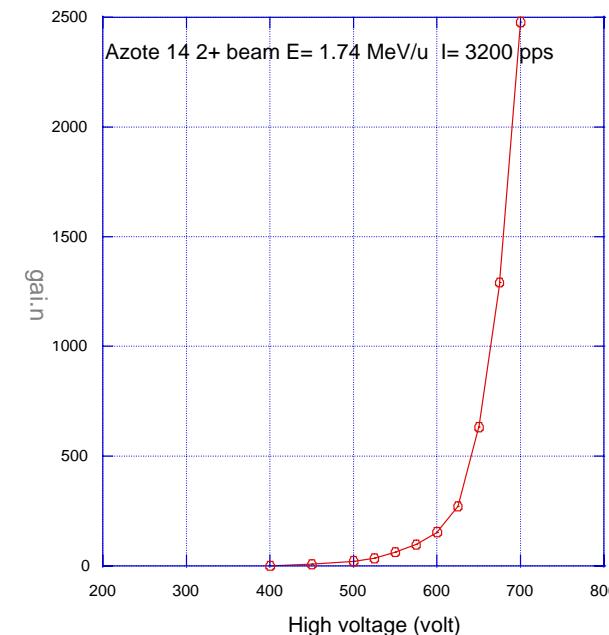
- Low Pressure Gas Monitor (LPGM)

Experimental result : Azote14 2⁺ beam profile E= 1.74 MeV/u, I= 3200 pps



Horizontal profile

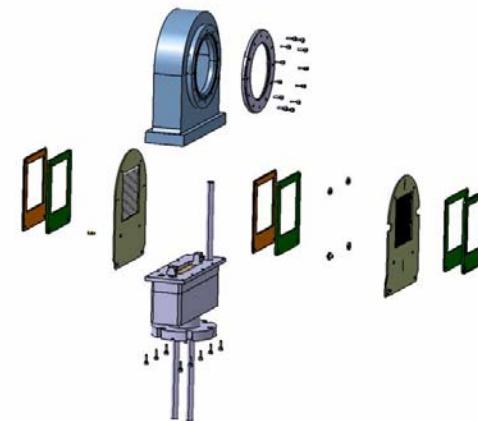
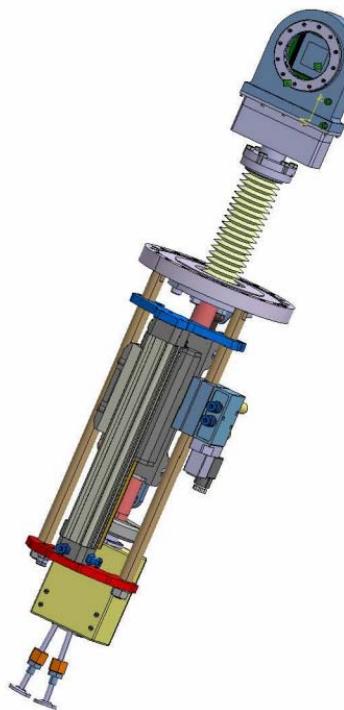
Vertical profile



amplification signal versus high voltage variation

- Low Pressure Gas Monitor (LPGM)

Further improvements : new design to increase the high voltage limitation, to limit the outgazing and to improve the gas circulation



Test in progress (JINR DUBNA):
comparaison of the irradiation flux
and thermal resistance between
Mylar and Kapton foils

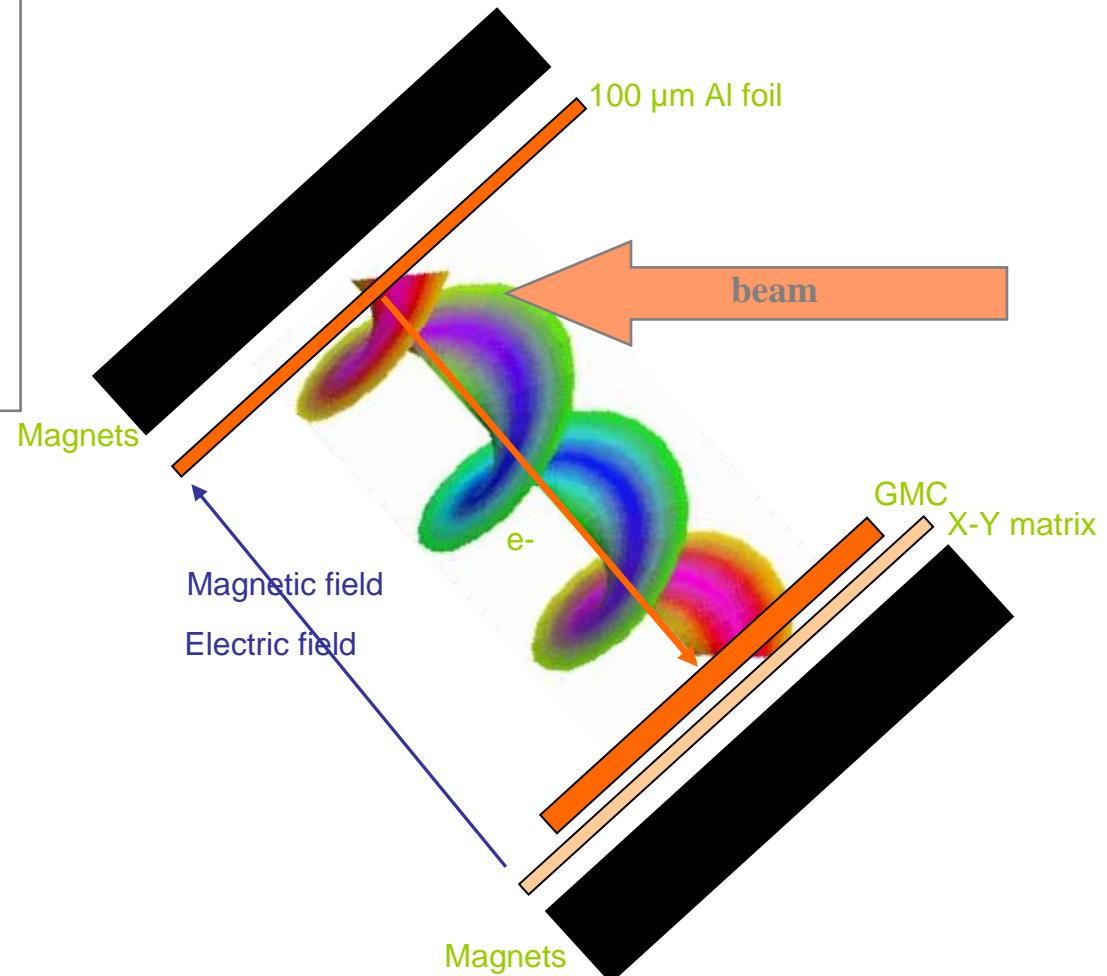
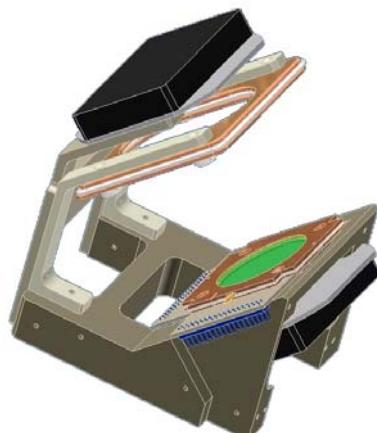
- Emissive Foil Monitor

Principle : secondary emission on Al foil, amplification by microchannel plates, reading informations on X-Y matrix

Energy range : up to 10 KeV

Intensity range : from 10 pps to 10^9 pps

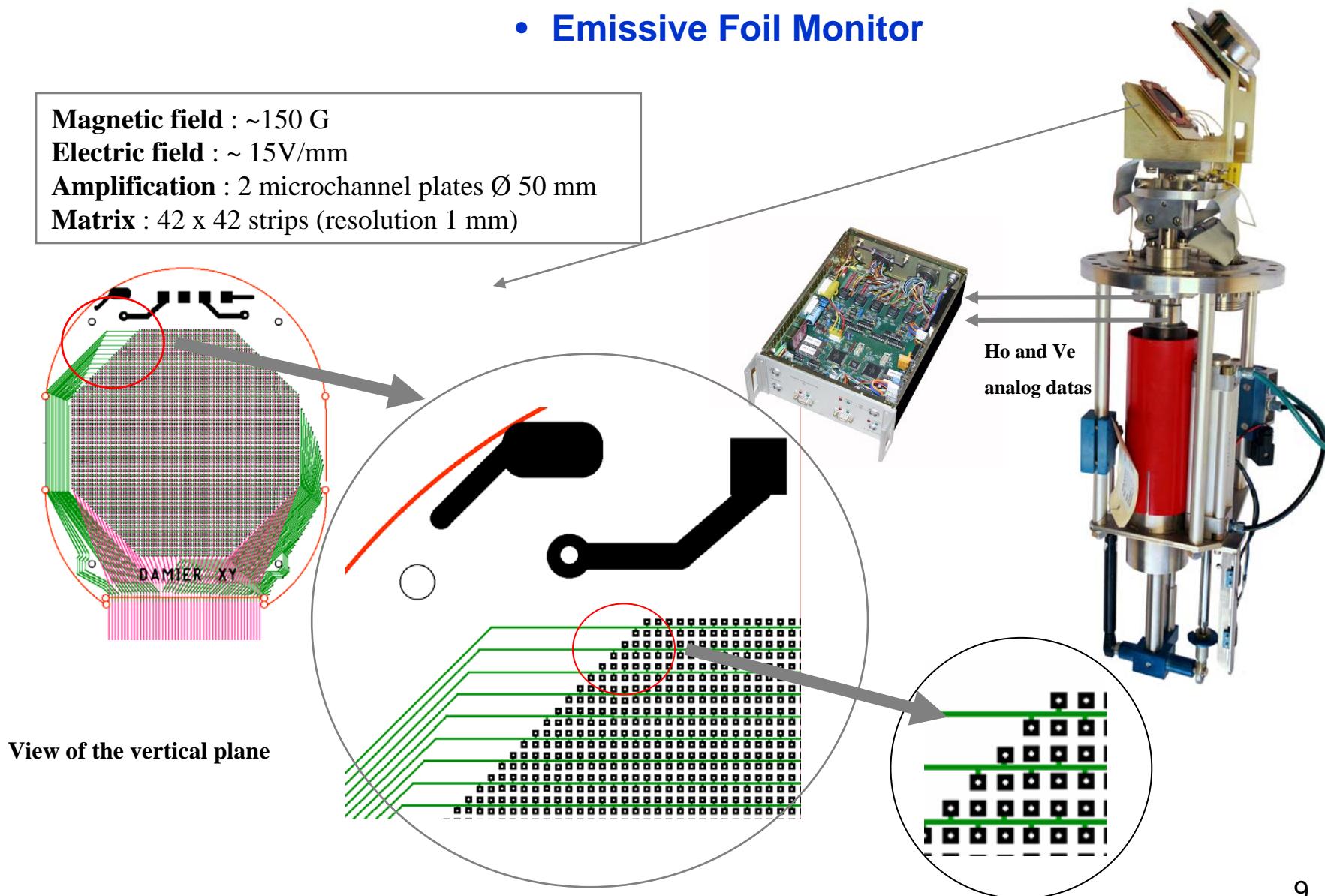
Location lines : from 1+ line to GANIL Experimental rooms



Radioactive ion beam profileurs

- Emissive Foil Monitor

Magnetic field : ~150 G
Electric field : ~ 15V/mm
Amplification : 2 microchannel plates Ø 50 mm
Matrix : 42 x 42 strips (resolution 1 mm)



9

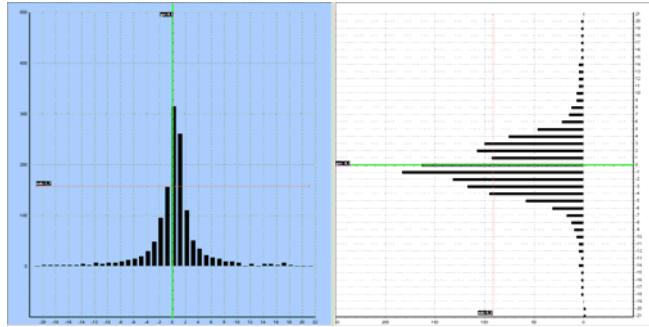
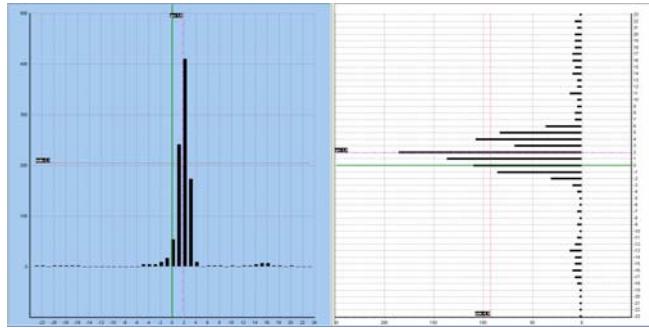
Radioactive ion beam profileurs

- Emissive Foil Monitor

Two Experimental results

C12 2⁺ beam at 5 MeV/u

Intensity : 10^4 pps



Horizontal profile

Vertical profile

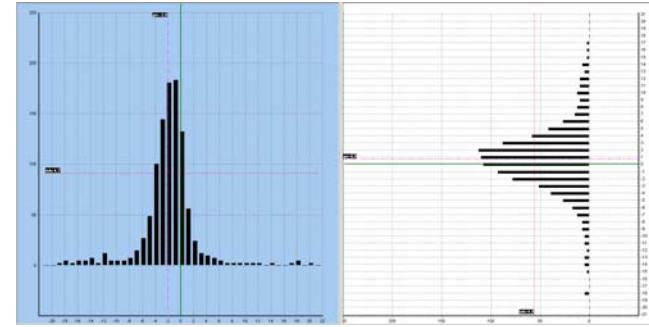
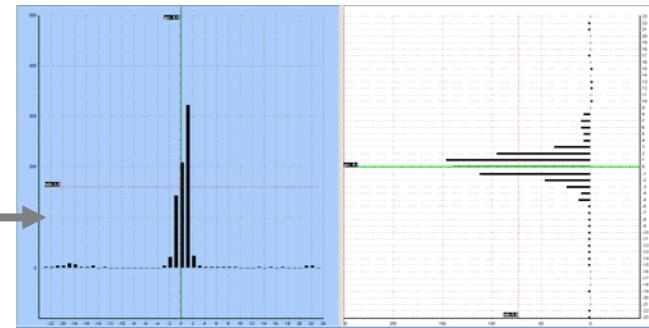
Reference Profiler :
gas profiler

SEM profiler

Emissive foil
monitor profile

Xe132 15⁺ beam at 15 KeV/u

Intensity : $2.5 \cdot 10^{10}$ pps



Horizontal profile

Vertical profile



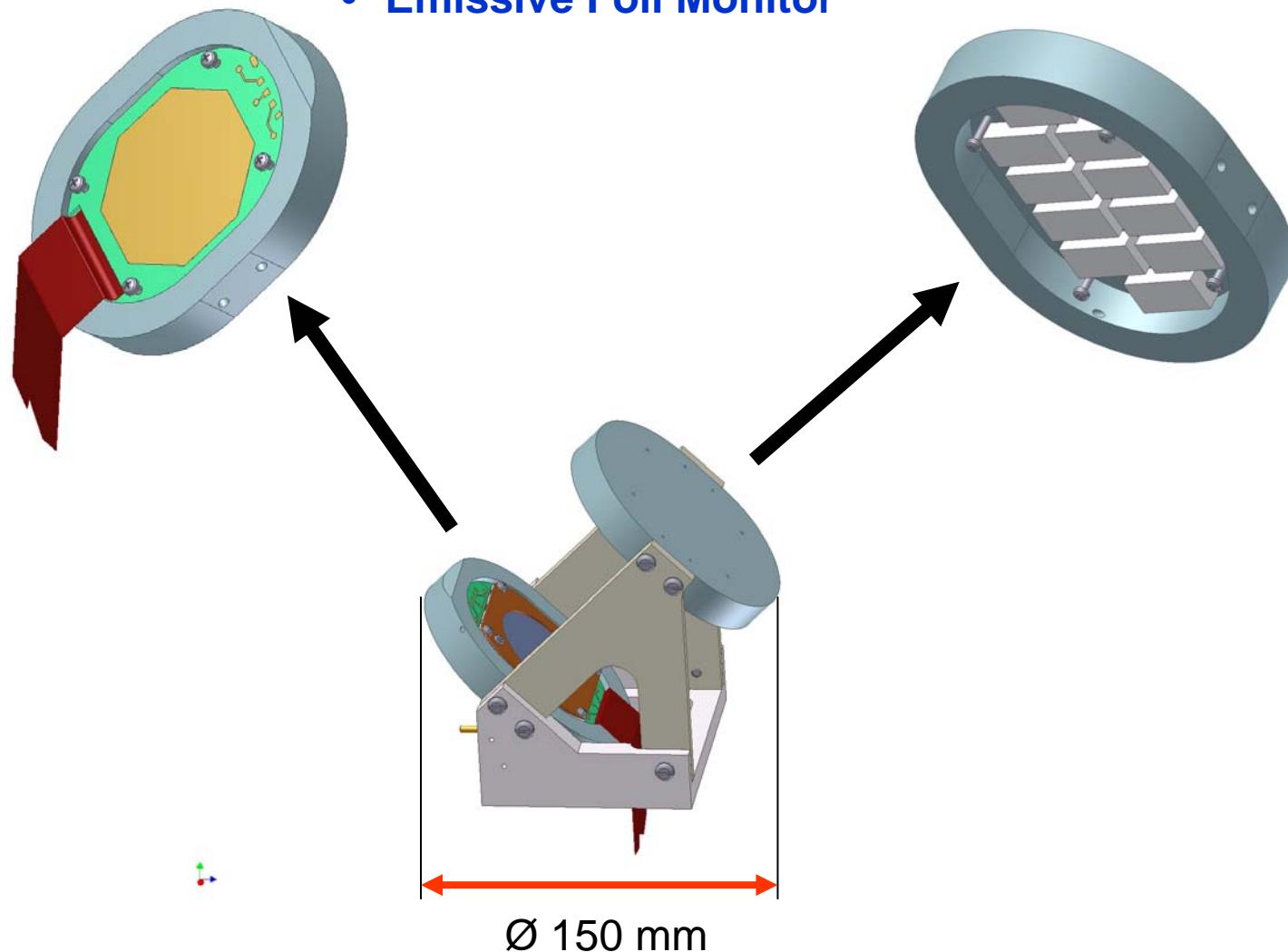
increase of the profile size



Needing to perform the resolution

Radioactive ion beam profileurs

- Emissive Foil Monitor



New design of magnets pole : beam test in 2010

Radioactive ion beam profileurs

- **Very Low Intensity Monitor (VLIM)**

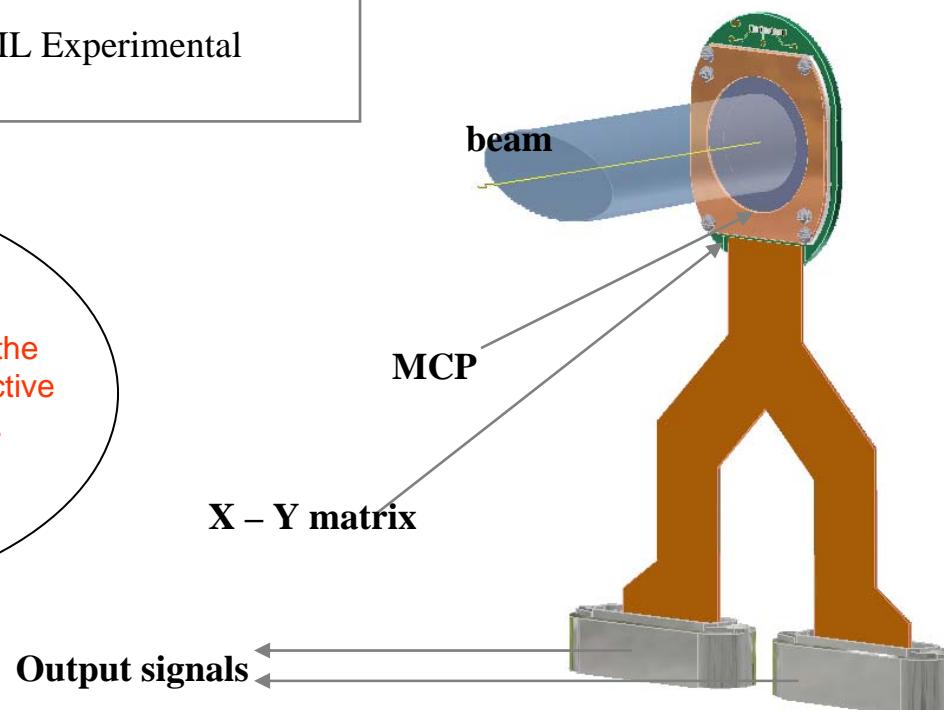
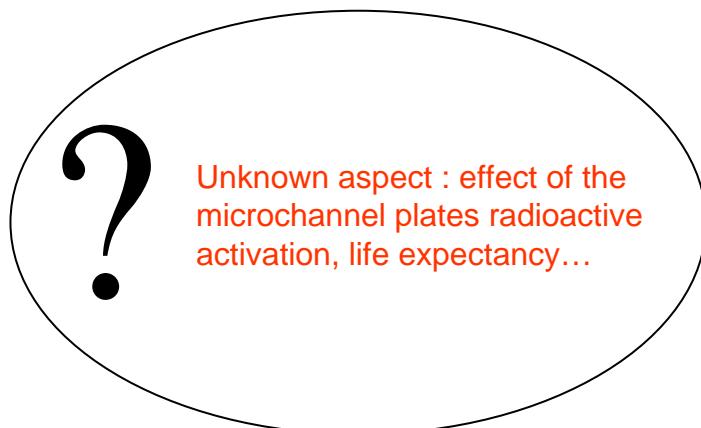
Principle : direct low intensity beam on MCP and matrix reading

Energy range : from 10 keV/u to 25 MeV/u

Intensity range : from 10 pps to 10^5 pps

Location lines : from 1^+ line to GANIL Experimental rooms

Under development : first test in 2010



Radioactive ion beam profileurs

- Associated electronics
(for all beam profile monitors)

Principle : 94 channels in a parallel system (2 x 47).

Two conversion possibilities: passive system for high intensity beams
active system for low intensity beams

Front end : constituted by 12 daughter boards of 8 channels

A/D conversion : about 4 μ s

Acquisition : FPGA (Altera cyclone 3)

For more informations :
gueroult@ganil.fr



Thank you for your attention